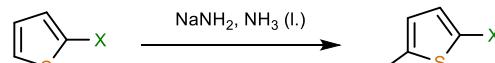
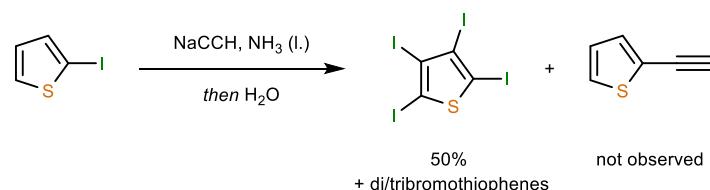
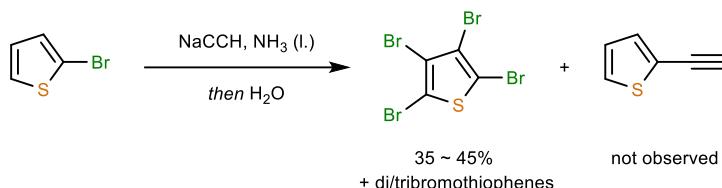


The First Halogen Dance (HD)

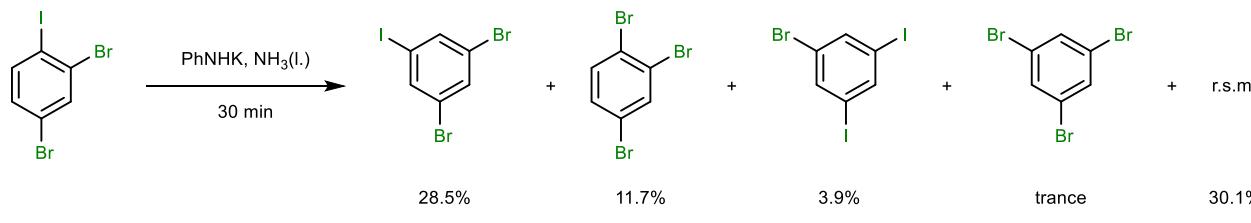


X	Eq. of NaNH_2	Yield%	r.s.m.%
Br	2	18	10
Br	1	36	35
Br	0.2	17	70
I	2	22	12
I	1	15	45
I	0.2	15	65

Vaitiekunas, A.; Nord, F. F. *Nature* **1951**, 168, 875. <https://doi.org/10.1038/168875a0>

Vaitiekunas, A.; Nord, F. F. *J. Am. Chem. Soc.* **1953**, 75, 1764. <https://doi.org/10.1021/ja01103a537>

Mechanistic Studies

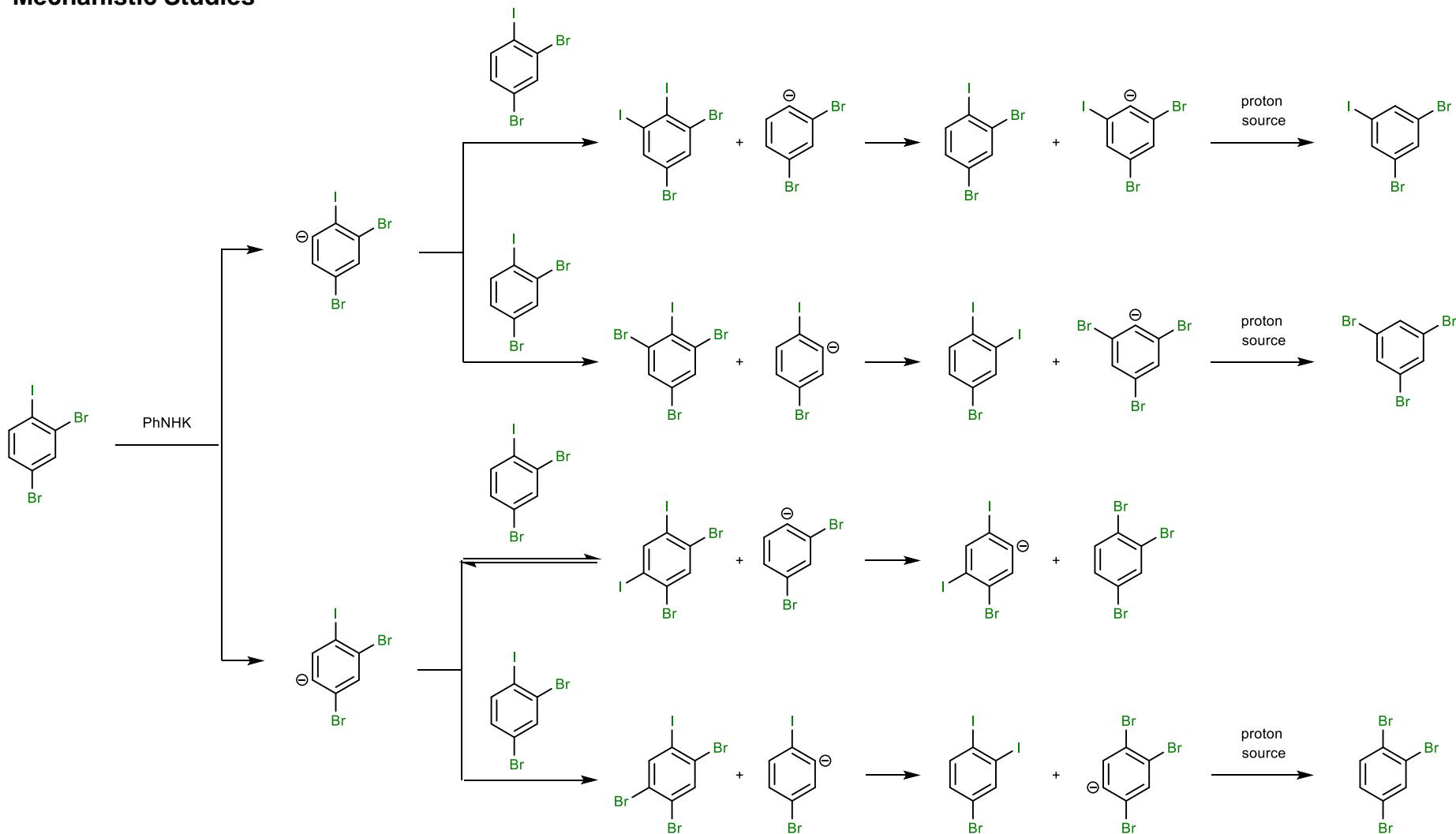


- External halogen ions did not affect the rearrangement process.
- Different patterns from addition to 3-haloarynes.
- The aryne mechanism cannot explain the formation of dihalo- and terahalo-products (Vaitiekunas' results).

Moyer, C. E.; Bunnett, J. F. *J. Am. Chem. Soc.* **1963**, 85, 1891. <https://doi.org/10.1021/ja00895a058>

Bunnett, J. F. *Acc. Chem. Res.* **1972**, 5, 139. <https://doi.org/10.1021/ar50052a004>

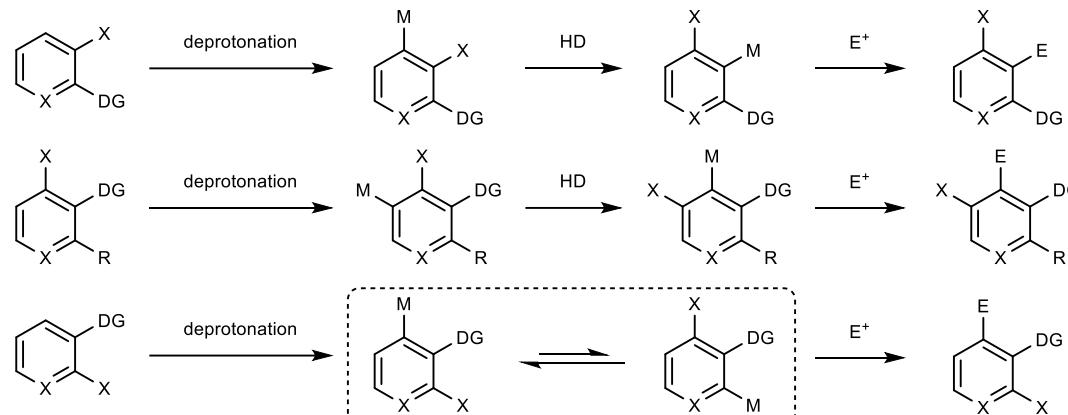
Mechanistic Studies



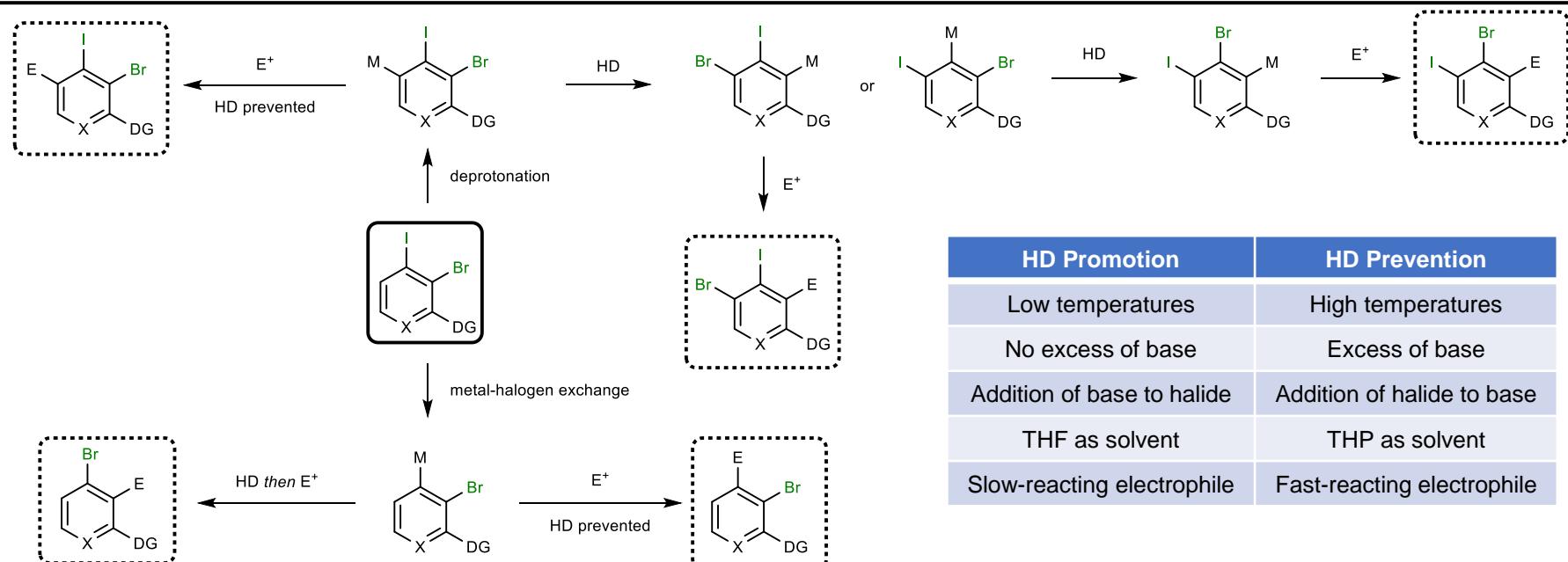
Moyer, C. E.; Bunnett, J. F. *J. Am. Chem. Soc.* **1963**, 85, 1891. <https://doi.org/10.1021/ja00895a058>
 Bunnett, J. F. *Acc. Chem. Res.* **1972**, 5, 139. <https://doi.org/10.1021/ar50052a004>

Formation of arynes not shown

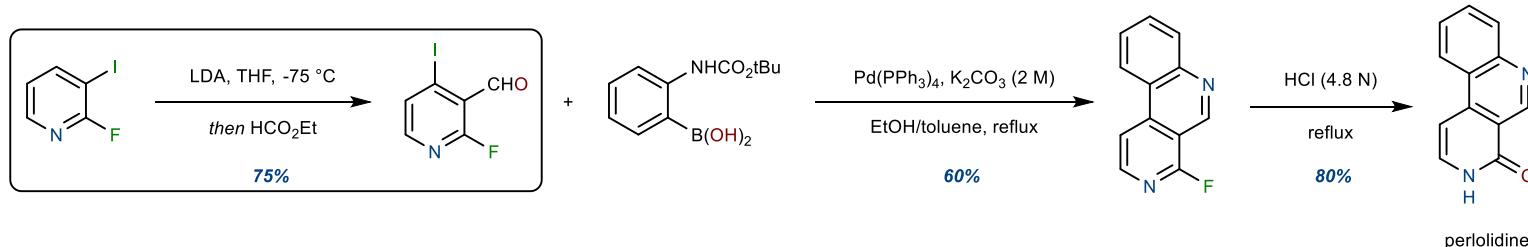
General Guidelines for the Control of Halogen Dance



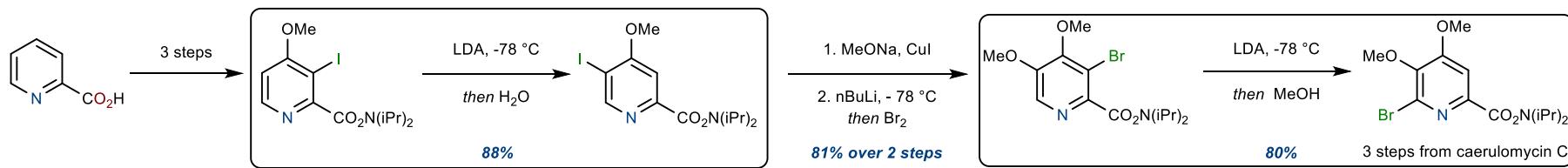
1. The thermodynamically most stable organometal species leads to the product
2. Migratory aptitude: I > Br >> Cl (F does not react)
3. HD can be minimized or completely prevented if undesired, a small amount of starting material is needed to initiate the rearrangement



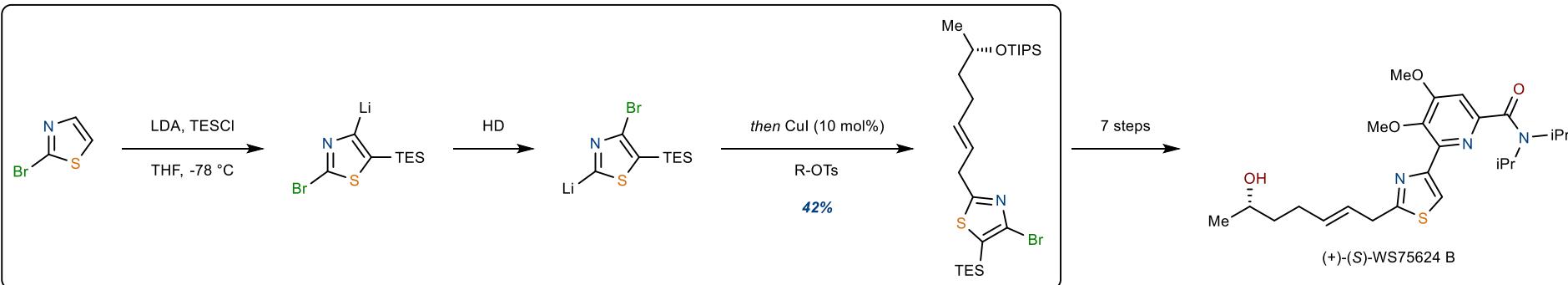
Synthetic Applications



Rocca, P.; Cochennec, C.; Marsais, F.; Thomas-dit-Dumont, L.; Mallet, M.; Godard, A.; Queguiner, G. *J. Org. Chem.* **1993**, 58, 7832. <https://doi.org/10.1021/jo00079a031>

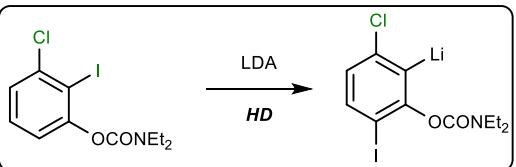


Sammakia, T.; Stangeland, E. L.; Whitcomb, M. C. *Org. Lett.* **2002**, 4, 2385. <https://doi.org/10.1021/o1026135m>



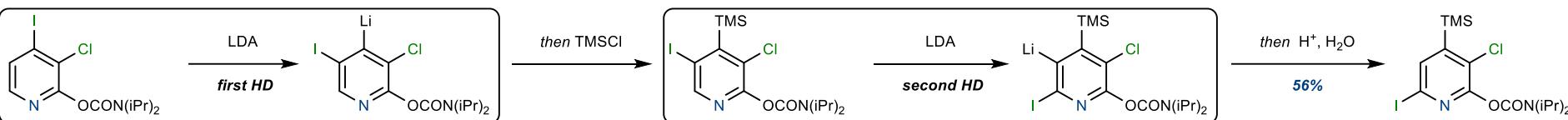
Stangeland, E. L.; Sammakia, T. *J. Org. Chem.* **2004**, 69, 2381. <https://doi.org/10.1021/jo0351217>

Synthetic Applications

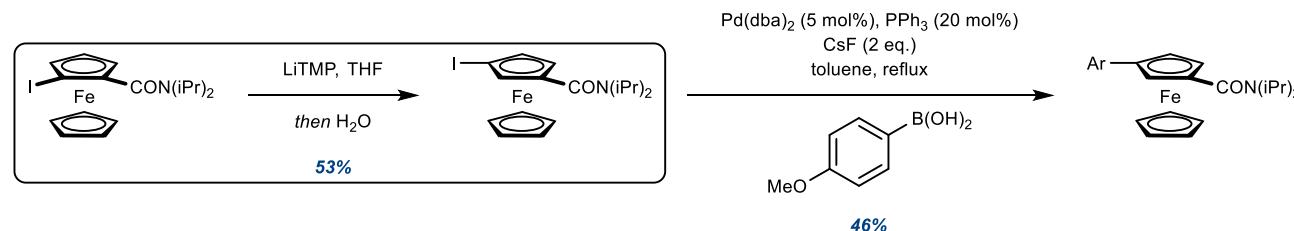


HD-Fries rearrangement cascade (left)

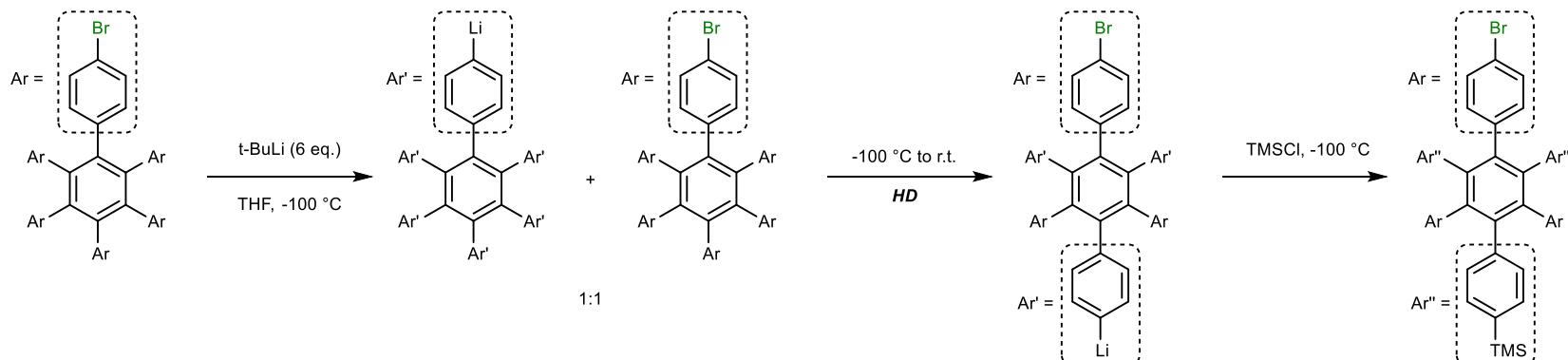
Double HD rearrangement (below)



Miller, R. E.; Rantanen, T.; Ogilvie, K. A.; Groth, U.; Snieckus, V. *Org. Lett.* **2010**, 12, 2198. <https://doi.org/10.1021/ol100493v>



Tazi, M.; Erb, W.; Halauko, Y. S.; Ivashkevich, O. A.; Matulis, V. E.; Roisnel, T.; Dorcet, V.; Mongin, F. *Organometallics* **2017**, 36, 4770. <https://doi.org/10.1021/acs.organomet.7b00659>



Kojima, T.; Hiraoka, S. *Org. Lett.* **2014**, 16, 1024. <https://doi.org/10.1021/ol500041j>